

Invalidation Search on a patent in the semiconductors space

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Complementary logic input parallel (CLIP) field effect transistor (FET) logic circuit

Problems and solutions in the prior art

Problem

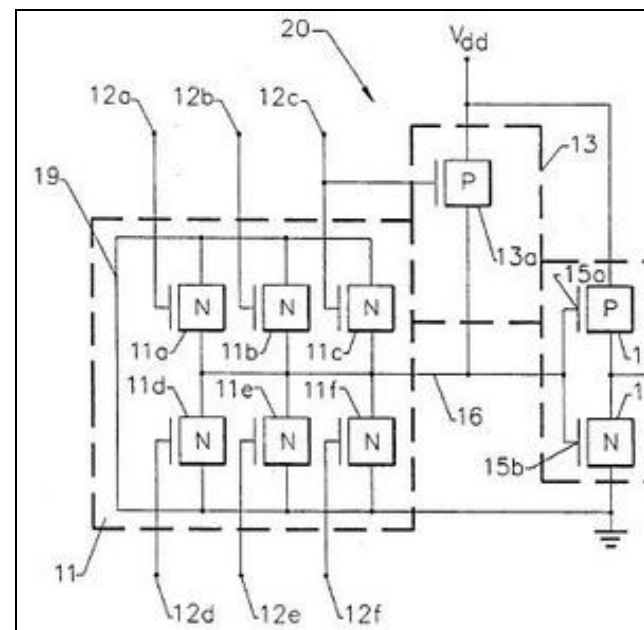
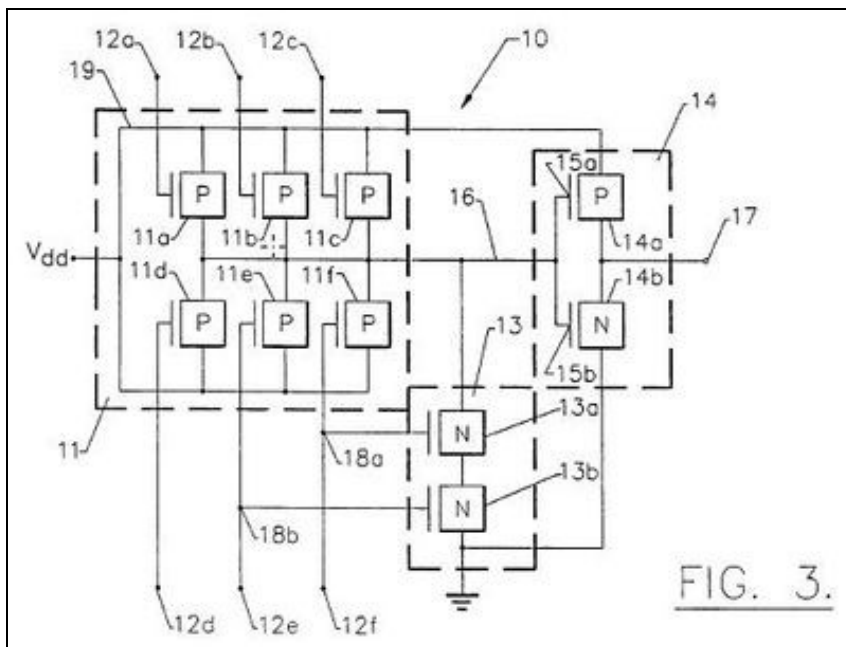
- Serial connection of the load transistors in conventional CMOS logic gates reduces the toggle rate or switching speed of the gate and also reduces the number of inputs which may be applied to the gate (referred to as "fan-in").

Solutions

- To overcome these problems an "all parallel" CMOS gate design has heretofore been proposed. Here serial load transistors are replaced by a first load which may be an MOS transistor or a resistor, and a second load comprising an MOS transistor having opposite conductivity type from the driver stage transistors.
- A high speed, high density low power dissipation complementary FET logic circuit is disclosed, in which the voltage transfer function of the logic gate's complementary FET inverter output stage is deliberately skewed to dramatically decrease the lift-off interval for the logic gate and thereby dramatically increase the speed of the gate

Problems and solutions for the present invention (CLIP AND & OR logic circuits)

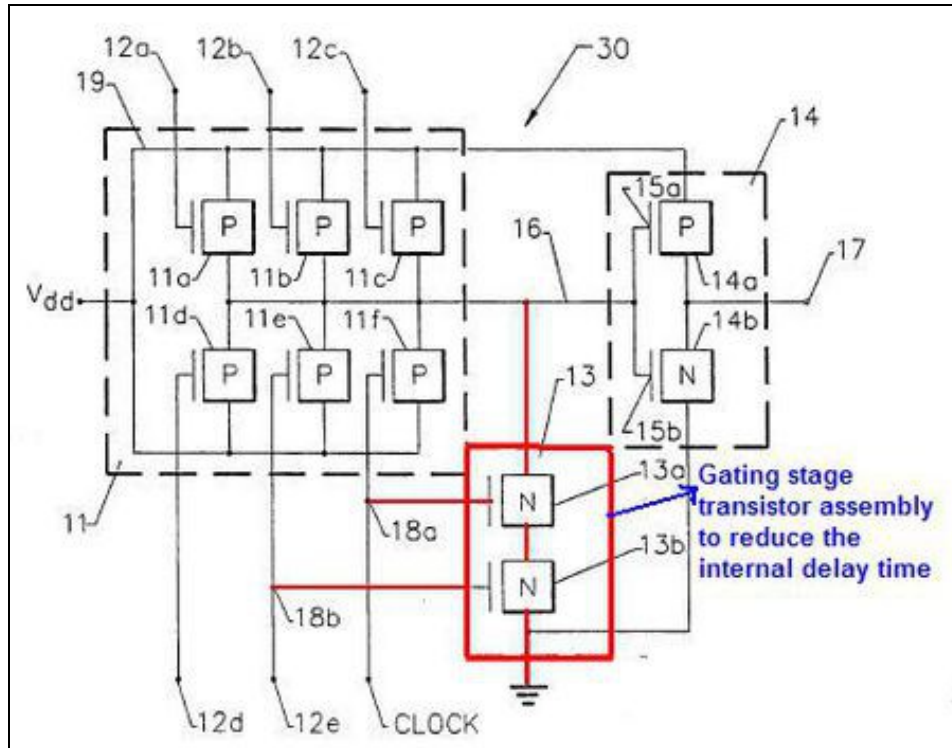
CLIP AND & OR logic circuits according to the invention



Problem - 1

- Rise and delay time was increased

Solution



- High speed logic circuit family in which the rise and delay times of the gate are minimized. In other words, the internal delay of the gate in providing a logic output signal which accurately reflects the state of the logic input signals must be minimized.
- It has been found, according to the invention that when the geometry of the gating FETs are arranged as described above, the internal delay time of the logic gate is dramatically decreased thereby improving the speed of the gate while still insuring reliable logic switching.
- **Geometry of gating FET's:** logic gate 10 also includes a gating stage 13 including a pair of gating transistors 13a, 13b serially connected between the common output 16 and the second reference potential (ground). As illustrated in FIG. 3, two gating transistors are used, however any number of gating transistors may be used. Control electrodes 18a and 18b are connected to the control electrodes 12f and 12e of transistors 11f and 11e respectively. Accordingly, gating transistors 13 are turned on when transistors 11e and 11f are turned off. It will be understood by those having skill in the art that control electrodes 18 may be connected to any of control electrodes 12.
- The dimensions of the gating FETs are controlled relative to the dimensions of the driving stage FETs to provide a high speed logic circuit

Problem - 2

- Lower saturation current and corresponding lower carrier mobility of P-channel device compared to N-channel limits the overall speed of the logic gate

Solution

- Provide a high speed complementary all-parallel FET logic family, the performance of which is not limited by the inherently lower saturation current and carrier mobility of P-channel FET devices.
- Speed of the CLIP logic circuits described above is further increased by including germanium in the channels of the P-channel FETs, to thereby increase the carrier mobility in the P-channel FETs. The N-channel FETs are free of germanium so that the carrier mobility of only the P-channel devices is increased. In a preferred embodiment up to 38 atomic percent of the silicon P-channel is germanium, to thereby substantially equalize the carrier mobility of the N-channel FETs and the P-channel FETs. Accordingly, the saturation current limitation of P-channel FETs is reduced and may even be eliminated. It will be understood by those having skill in the art germanium may be included in P-channel FETs of all complementary FET logic circuits to thereby equalize the carrier mobilities in the P and N-channel devices and thereby increase the logic circuit speed.

Problem - 3

	Abstract	minimize the capacitance, minimize delay time	performance)) OR ((minimize* or reduc* or lower* or (cut adj1 down)) NEAR capacitance) OR ((minimize* or reduc* or lower* or (cut adj1 down)) NEAR delay)) Priority Date (earliest): <19910131	
2	Claims, Title or Abstract	Increase the speed of the logic circuits that includes transistors	Query - (increase or step adj1 up or increment or high OR enhanc*) SAME ((logic adj1 (circuit or gate or stage)) AND ((p or n) adj2 (channel or type) NEAR (transistor or *FET*1 or (field adj1 effect adj1 transistor*)))) Priority Date (earliest): <19910131	32
3	Claims, Title or Abstract	FET?s connected in parallel with the drains connected to Vdd	Query - ((p or n) adj2 (channel or type) NEAR (FET*1 or (field adj1 effect adj1 transistor*))) WITH parallel WITH (Vdd or potential or supply) Priority Date (earliest): <19910131	58
4	Full patent spec.	FET?s connected in parallel to increase the speed	Query: ((p or n) adj2 (channel or type) NEAR (FET*1 or (field adj1 effect adj1 transistor*))) WITH parallel WITH (Vdd or potential or supply) AND (logic adj1 (circuit or gate)) AND (((increase or step adj1 up or increment or high) NEAR (speed or performance)) OR ((minimize* or reduc* or lower* or (cut adj1 down)) NEAR capacitance) OR ((minimize* or reduc* or lower* or (cut adj1 down)) NEAR delay)) Priority Date (earliest): <19910131	33
5	Full patent spec.	FET Connection having common output	Query - ((p or n) adj2 (channel or type) NEAR (*FET*1 or (field adj1 effect adj1 transistor*))) SAME (parallel and (Vdd or potential or supply) and (common adj1 output)) Priority Date (earliest): <19910131	22
6	Full patent spec.	FET?s with channel width, channel lengths and saturation current described	Query: (channel adj1 (width and length)) and (saturation adj1 current) and ((p or n) adj2 (channel or type) NEAR (FET*1 or (field adj1 effect adj1 transistor*))) Priority Date (earliest): <19910131	13
7	Full patent spec.	FET?s of gating stage connected serially to common output and ground	Query: ((p or n) adj2 (channel or type) NEAR (FET*1 or (field adj1 effect adj1 transistor*))) WITH (((serial or serially) NEAR2 (connected or connection)) and (ground or VSS or potential)) Priority Date (earliest): <19910131	98
8	Claims	Increasing the speed in the logic circuits	Query - (increase or step adj1 up or increment or high) WITH (logic adj1 (circuit or gate)) AND (transistor or FET*1 or (field effect transistor*)) and speed Priority Date (earliest): <19910131	100
9	Full patent spec.	Common diffusion to minimize the internal capacitance	Query: ((common or shared or mutual) WITH diffusion) and ((minimize* or reduc* or lower* or (cut adj1 down)) NEAR capacitance) AND (FET or (field adj1 effect adj1 transistor*) or transistor) Priority Date (earliest): <19910131	48
10	Full patent spec.	Increasing the carrier mobility in P-channel FET?s by doping germanium	Query - (p adj2 (channel or type) NEAR (transistor or *FET*1 or (field adj1 effect adj1 transistor*))) AND ((increase or step adj1 up or increment or high or enhanc* or equalize) NEAR (carrier NEAR mobil*)) AND germanium Priority Date (earliest): <19910131	12
11	Total		1 OR 2 OR 3 OR 4 OR 5 OR 6 OR 7 OR 8 OR 9	542

Note: Other databases will also be used to run these queries with the respective operators of the databases. Databases includes SIP, Google patents etc

Non patent search

Technical Articles

- Database used - Google scholar that covers IEEE
 - ◆ Years - 1985-1990

S.no	Query	Hits
1	P N channel FET logic increase OR enhance OR high "speed"	399
2	P channel FET logic speed increase OR enhance OR high "germanium"	52
3	FET logic parallel speed drain increase OR enhance OR high OR Vdd OR potential -patents	267
4	FET logic parallel speed increase OR enhance OR high OR Vdd OR potential "common output"	30
5	P N channel FET logic speed inverter OR complimentary "common output"	4
6	P-channel N-channel FET common diffusion "parallel"	114
7	P-channel N-channel FET germanium increase OR enhance OR high "carrier mobility"	9
8	P-channel N-channel FET germanium increase OR enhance OR high "carrier mobilities"	3
9	P-channel N-channel FET germanium increase OR enhance OR high "saturation current"	6
10	P-channel N-channel FET minimize OR decrease OR reduce "internal capacitance"	4
11	Total	888

Magazine articles

- Found one relevant articles from BYTE magazine.
 - ◆ Gallium Arsenide Chips - Volume 9, issue 12 (November, 1984)

Non-Patents Analysis

Analysis 1

NAME	CLIP FET		
<p>FIGURE</p>			<p>Gating Stage - P channel connected to VSS and Common Output</p> <p>Inverter Stage - P and N channel FETs connected</p> <p>Driver Stage - N channel FET connected in parallel</p>
TYPE	Patent:- US5247212	IEEE JOURNAL OF	
Title	Complementary logic input parallel (CLIP) logic circuit family	A 15-ns CMOS 64	
Assignee	THUNDERBIRD TECH INC (US)	STANLEY E. SCH... L. FRANCH, PAUL... PETER W. COOK... WILLIAM F. POKO...	
IPC	H01L21/8238; H01L27/092; H03K3/356; H03K19/0948; H03K19/096; H01L21/70; H01L27/085; H03K3/00; H03K19/0948; H03K19/096; (IPC1-7): H03K17/04; H03K19/003; H03K19/017; H03K19/094; H03K19/20		
Priority date	19910131		
Filing date	19910131		
Publication date	9/21/1993	11/5/1986	
Driving stage	P channel FET (CLIP AND gate) / N channel FET (CLIP OR gate)	N channel FET	
Connection 1	FET being connected between a common output and a first potential level (Vdd)	FET being connect	
Connection 2	Control electrode of driving stage FET for receiving logic input signals (Multiple)	Control electrode of	
Gating stage	N channel FET (CLIP AND gate) / P channel FET (CLIP OR gate)	P channel FET	
Connection 1	FET being connected between a second potential level (Ground or Vss) and common output.	FET being connect	
Connection 2	Control electrode of gating stage FET is connected to a control electrode of driving stage FET,	Control electrode of... shown in figure. It	
Complementary FET inverter	Complimentary P & N channel FETs	Complimentary P	
Connection 1	FET?s are serially connected between said first and second potential levels (Vdd and (Vss or grnd))	FET?s are serially	
Connection 2	Inverter input being connected to common output.	Inverter input bein	

$$Z_n = \frac{I_{satp}^*}{I_{satn}^*} Z_p \left(\frac{L_n}{L_p} \right) \frac{S_n}{2}$$

Zg - channel width of gating transistors, Zd - channel width of driving transistors, I@*satd - saturation current for square channel driving transistor, I@*satg - saturation current for square channel gating transistor, Lg - channel length of gating transistors, Ld - channel length of driving stage transistors, and Sg - number of gating transistors

Since the connect

Analysis 2

- Claim 21 - Germanium doped P-channel FET
- The document describes germanium doped P-channel FET for increasing the channel mobility (Page 2630)

Marked document

- 15-ns CMOS 64K RAM
- Germanium p-Channel MOSFET's with High Channel Mobility

Conclusion

- The article describes a similar driving stage, gating stage and inverter stage as shown in the above table. Only one extra stage for low order bits is added which is optional can be seen in the figure listed to the right side of above table shown as unmarked stage.
- Hence the article invalidates the inforce patent